

OR1407

Investigations on the active screen plasma nitriding process

Kristian Börner¹, Igor Burlacov¹, Heinz-Joachim Spies¹, Horst Biermann¹,
Stephan Hamann², Jürgen Röpcke²

¹Institute of Materials Engineering, Freiberg, Germany ²INP Greifswald,
Greifswald, Germany

boerner1@mailserver.tu-freiberg.de

This study presents the mechanism of nitrogen transfer in a large scale active screen plasma nitriding (ASPN) unit. The active screen provides a homogeneous temperature distribution within the workload as well as an arcing tendency is reduced, since the plasma is moved from the treated work pieces to the active screen. In order to study the mechanisms in detail, plasma diagnostics is necessary.

The applied diagnostic methods for analyses of the excited process gas synthesised by the active screen include mass spectrometry and infrared diode laser spectroscopy (TDLAS). Together with a metallurgical characterisation of nitrided steels a better understanding of the chemical phenomena in the N₂-H₂ plasmas is achieved. Various N₂/H₂ gas mixtures and variable bias activation powers at the pressure of 200 Pa were investigated. The main active species governing the nitriding process i.e. N, N₂, NH or NH_x in excited or ionized form were analysed. It was found that even during heating up in nitrogen free process gas excited nitrogen (atomic or molecular) releases from the active screen. Infrared diode laser spectroscopy has been used as a diagnostic method to measure the concentrations of the stable NH₃ molecules downstream the plasma source. The ammonia production turns out to depend on the mixtures of N₂-H₂ and the current input of the bias activation. The results are discussed with the plasma parameters measured by the electrostatic probe. Thus, a contribution to the interpretation of the mass transfer in ASPN processes has been realised.

Keywords

Active screen plasma nitriding
mass transfer mechanism
mass spectrometry
Absorption spectroscopy